

- As mentioned above, material grown under compression is usually more stable to relaxation than material under tension, allowing one to err more toward negative values of $\Delta\theta$.
- Because of dynamical scattering effects, the measured $\Delta\theta$ for a thin ($\leq 0.1 \mu\text{m}$) epilayer will be less than that of a thicker layer with the same composition and lattice mismatch [39].
- The value of $\Delta\theta$ for epilayers grown on nonsingular (100) substrates is not unique, but depends on the orientation of the substrate with respect to the X-ray beam. The effective $\Delta\theta$ is the average of two measurements of $\Delta\theta$. The first measurement is made in the conventional manner; the second measurement is made with the sample rotated by 180° [40]. For vicinal substrates close to (100), this effect is small, usually $\sim 10\%$ at misorientation of 6° ; however, for {511} substrates, the effect is closer to 50%.

9.6.3.2 Optical properties of GaInP

9.6.3.2.1 Ordering in GaInP

Prior to 1986, it was generally assumed that the band gap of a III-V ternary alloy semiconductor such as $\text{Ga}_x\text{In}_{1-x}\text{P}$ was a unique function of the composition, and most publications showed $\text{Ga}_x\text{In}_{1-x}\text{P}$, lattice matched to GaAs, as having a band gap of 1.9 eV. However, in 1986 Gomyo *et al.* [42] reported that the band gap of $\text{Ga}_x\text{In}_{1-x}\text{P}$ grown by MOCVD was usually less than 1.9 eV and depended on the growth conditions. In a subsequent paper [43], they showed that the band gap shift was correlated with the ordering of Ga and In on the Group III sublattice. The ordered structure is CuPt-like, with alternating {111} planes of $\text{Ga}_{0.5+\eta/2}\text{In}_{0.5-\eta/2}\text{P}$ and $\text{Ga}_{0.5-\eta/2}\text{In}_{0.5+\eta/2}\text{P}$, where η is the long-range order parameter. Perfectly ordered GaInP ($\eta = 1$) would be composed of alternating {111} planes of GaP and InP. The first theoretical treatments of ordering in $\text{Ga}_x\text{In}_{1-x}\text{P}$ were put forward by Kondow and coworkers [44] using the tight binding theory, and by Kurimoto and Hamada [45] using the “first-principles” Linearized Augmented Plane Wave (LAPW) theory.

The functional relationship between the band gap’s change, ΔE_g , and the order parameter for GaInP was first published by Capaz and Koiller [46]:

$$\Delta E_g = -130\eta^2 + 30\eta^4 \quad (\text{in meV}) \quad (9.20)$$

A more recent result [47] suggests that

$$\Delta E_g = -484.5\eta^2 + 435.4\eta^4 - 174.4\eta^6 \quad (\text{in meV}) \quad (9.21)$$

The effects of various growth parameters on the ordering and the band gap of $\text{Ga}_x\text{In}_{1-x}\text{P}$ have been studied extensively. The band gap of $\text{Ga}_x\text{In}_{1-x}\text{P}$ is a function not only of the growth temperature, T_g , but also of the growth rate, R_g , the phosphine partial pressure, P_{PH_3} , substrate misorientation from (100), and the doping level. Some of these effects are illustrated in Figure 9.14. Although the behavior is very complicated, there are a few characteristics that stand out. For example, for substrates that are closely oriented to within a few degrees of (100), the band gap of GaInP, using typical values for T_g , R_g , and